

Oxygen induced surface structure of Mo(110) studied by scanning tunneling microscopy

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Abstract

The oxygen induced surface structures formed on Mo(110) by oxygen exposure at 1300 K in UHV has been studied by scanning tunneling microscopy (STM). Two kinds of oxygen-adsorbed surface structures are observed. One consists of one-dimensional rows running along $[\bar{1}11]$ or $[1\bar{1}1]$ directions at substrate molybdenum lattices, and another shows more complex structure including discrete arrangement of large protrusions and zig-zag alignments of small protrusions. This complex structure is probably a further oxygen-adsorbed structure than the well-known $p(2 \times 2)$ structure of 0.3 ML coverage. On the basis of STM image, an atomic model is proposed, where adsorbed oxygen atoms occupy both long-bridge and the quasi-threefold sites of molybdenum lattice (0.4 ML coverage). This structure is presumed to be a transient state during site-conversion with increase of oxygen exposure.

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1. Introduction

Molybdenum is industrially important as a heat-resistant and raw-material of alloys. Oxidized molybdenum is also important because of its high catalytic activity for selective oxidation of olefins and alcohols as well as reduction of nitrogen oxides [1–6]. When the oxide films are formed via oxygen adsorption, facetting occurs usually. Thus, it is well-known that MoO₂ and MoO₃ with various shapes including whiskers and nanorods are formed [6,7], leading to the application to nanodevices such as well-controlled arrays of quantum wires and dots. However, in order to design and control the nanostructures, it is important to know the initial oxidation behavior with atomic resolution. Mo(110) is the closest packed plane having high reactivity [7]. For oxygen adsorption on Mo(110), low energy electron diffraction (LEED) study

has shown that a $p(2 \times 2)$ structure is formed at first and more complex structure is formed at higher coverage than ~ 0.3 ML [8,9]. In addition, the initial adsorption sites during oxygen exposure were identified by high-resolution electron energy loss spectroscopy (HREELS) [10,11].

Scanning tunneling microscopy (STM) is a method to observe surface structure in real space with atomic resolution. As for interaction between oxygen and molybdenum surface, STM measurements have been conducted for oxygen adsorption on Mo(112). Schroeder et al. [12,13] and Santra et al. [14] proposed oxygen induced Mo(112) surface structures from the analysis of STM images. In their studies, $p(1 \times 2)$, $p(1 \times 3)$ and $p(2 \times 3)$ superstructures have been reported. Furthermore, McAvoy et al. [15] observed many nanostructures including line shaped and checker-flag-like structures on the oxygen adsorbed Mo(112) with some contaminations. On the other hand, no detailed STM study of the low-indices Mo(110) surface with oxygen exposure has been conducted so far.

In the present study, oxygen adsorbed structure of Mo(110) surface at low coverage has been observed by means of STM. The complex superstructures were

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observed to be formed by our procedure of the oxygen exposure. Furthermore, a structural models were proposed from atom-resolved STM images and were compared with other structure reported using LEED and HREELS.

2. Experiment

The present experiment was carried out at room temperature in an ultra-high vacuum (UHV) chamber with a pressure below 2×10^{-8} Pa. A Mo(110) specimen (14 mm $\times$ 3 mm, 0.25 mm of thickness) was fixed on the ceramic sample holder using Ta plates. STM observations were performed using an electrochemically etched W tip with the constant-current mode. Heating was performed using the ceramic heater underneath the specimen. The temperature of the specimen surface was measured by optical pyrometer.

The specimen was cleaned by Ar^+ sputtering followed by annealing in UHV. Both sputtering and annealing were performed at 1300 K for 1 h. In order to prepare the spec-

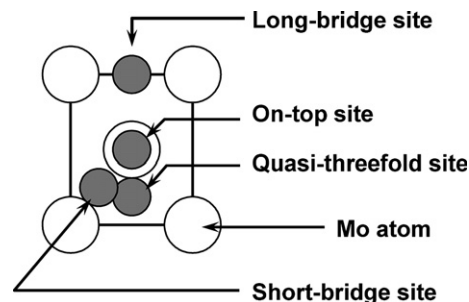


Fig. 1. Adsorption sites on Mo(110) unit cell. The white and gray balls stand for Mo and O atoms, respectively.

imen surface of low oxygen coverage, (1) heating in O_2 (4×10^{-6} Pa for 10 min) and in UHV (for 10 min) were repeated several times, followed by flashing, and then (2) the specimen was annealed at 1300 K in UHV for 5–45 min to prepare atomically well ordered surfaces. Step (2) is similar to the cleaning procedure performed by Kröger et al. [16] except for the heating temperature. They achieved a clean

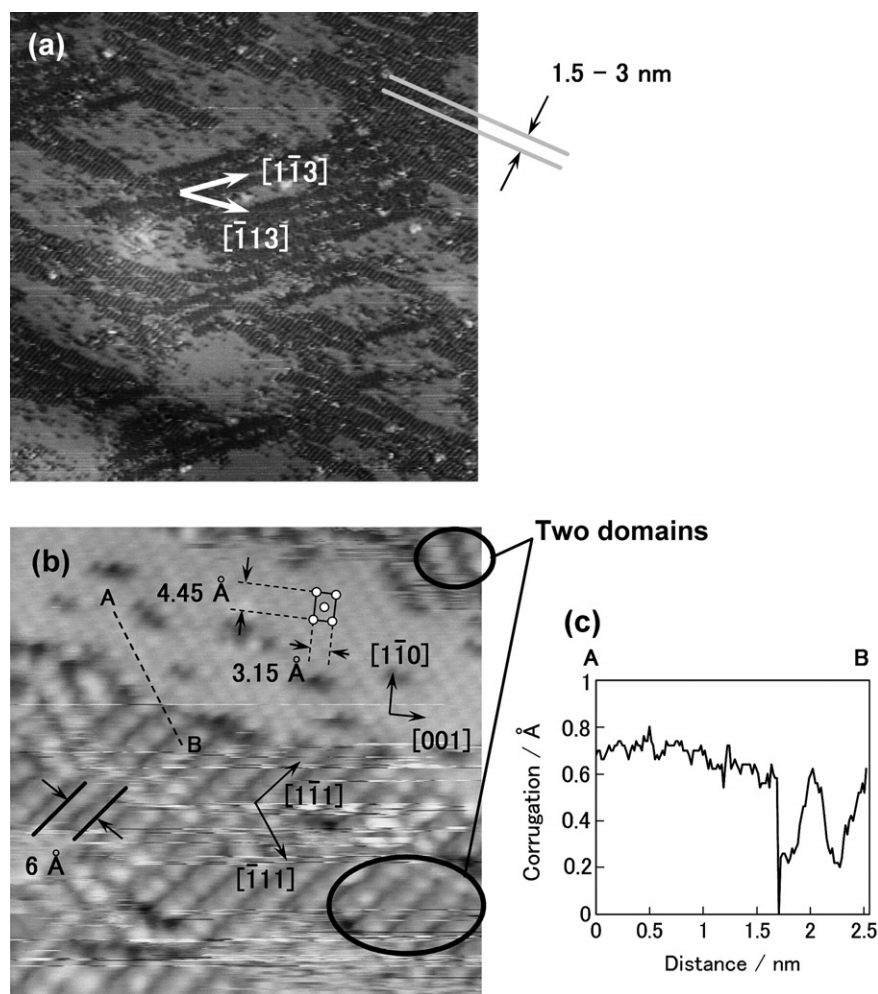


Fig. 2. (a) A STM topographic image of Mo(110) surface after Ar^+ sputtering and annealing at 1300 K for 1 h (56.9 nm $\times$ 56.9 nm, $V_s = -1.0$ V, $I_t = 0.2$ nA). (b) An enlarged image of cleaned Mo(110) sample (8.1 nm $\times$ 8.1 nm, $V_s = -1.0$ V, $I_t = 0.3$ nA). The clean area is observed relatively bright in which the unit cell is indicated. Around the clean area, two-domain structure which shows atomic rows running along $[\bar{1}11]$ and $[\bar{1}\bar{1}1]$ directions due to residual oxygen. (c) A cross-section of the clean area indicated by dashed line AB in (b).

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